



Docket No. 0524-0140.01

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of: )

Nozawa et al. )

Serial No.: 10/667,823 )

Filed: September 22, 2003 )

For: Phase Mask Shift Blank, Photo Mask Blank, )  
And Manufacturing Apparatus And Method )  
Of Blanks )

Examiner: Rodney Glenn McDonald )

Art Unit: 1753 )

Commissioner of Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited  
with the United States Postal Service as first class mail in an  
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Shannon Wallace

Name of applicant, assignee, or Registered Rep.

Shannon Wallace  
Signature

1/23/06  
Date

AMENDMENT (C) AFTER FINAL

Dear Sir:

In response to the Final Rejection of October 24, 2005, please enter the following amendment  
in the above-identified application:

*entered per Rec  
filed 2/27/06  
na*